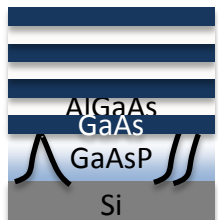
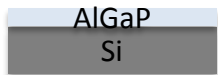


AlGaP coatings plans: growth



Structure	Purpose	Characterization
AlGaP/GaP mirrors on Si	Study interface effects: vary # of mirror pairs	<ul style="list-style-type: none"> Mechanical loss (disk, cantilever) RT and low T absorption XRD, TEM, AFM
AlGaP on Si	Study bulk AlGaP properties	<ul style="list-style-type: none"> Mechanical loss (cantilever) XRD, TEM, AFM, nanoindentation
GaP on Si	<ul style="list-style-type: none"> Study bulk GaP properties Control defect annihilation 	<ul style="list-style-type: none"> Mechanical loss (cantilever) RT and low T absorption XRD, TEM, AFM, nanoindentation
Nucleation layer (10 ML) on Si	Reduce atomic-scale defect formation	<ul style="list-style-type: none"> AFM, TEM (EELS, HAADF), RDS
AlGaAs/GaAs on Si	Study effect of dislocations on mech loss and absorption	<ul style="list-style-type: none"> Mechanical loss Absorption XRD, TEM

- Glasgow measurements of initial MBE GaP/AlGaP coating on going
 - Collaboration with Stanford ongoing – hopefully a second MBE GaP/AlGaP coating for further studies of this material
 - GaP single layer coatings on silicon cantilevers to be made by Kelvin Nanotechnology (KNT) and measured at Glasgow
 - Study multilayer physics from single layer measurements

- Silicon disk to be sent to Garrett Cole to have AlGaAs coating transferred on to it
 - Disk will be measured at Glasgow throughout the temperature range 12-300K